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Eigenstates and Absorption Spectra of Interdiffused AlGaAs–GaAs Multiple-Quantum-Well Structures

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Abstract—We present a comprehensive analysis of the interwell coupled eigenstates in interdiffused AlGaAs–GaAs multiple-quantum-well structures. A full numerical calculation is considered without any approximation or presumption of the eigenstates. During the initial interdiffusion in the quantum-well structure with well and barrier thickness equaling 100 Å, the wavefunctions behave as in the case of a single quantum well with almost no well-to-well coupling of the states. However, as interdiffusion proceeds, the eigenstate in each subband forms minibands, as in the case of superlattice. Distortion of the coupled wavefunctions can also be observed as a consequence of the nonuniformity of the confined wells at the far sides of the multiquantum-well core. The polarized absorption coefficients, including valence band-mixing, are also calculated. Results show that the blue shift of the absorption edge is greater in the range of $10 \text{ Å} \leq L_d \leq 30 \text{ Å}$. The two-dimensional quantum-well properties are at its strongest in the beginning of interdiffusion. An estimation of the modulator performance also shows an improvement of the contrast ratio and lower absorption loss during the initial stage of interdiffusion. This predicts wavelength tuning range of almost 60 nm.

I. INTRODUCTION

INTERDIFFUSED nonsquare single- and multiple-quantum-well structures are currently attracting considerable interest for their applications in optoelectronics [1]. This stems from both a fundamental point of view as well as from the realization of high-performance devices and the fabrication of optoelectronic integrated circuits [2]. The interdiffusion process¹ is produced by using post-growth thermal annealing to induce the solid-state interdiffusion of atoms (such as Al and Ga) through the quantum-well (QW) heterointerfaces (such as AlGaAs–GaAs) which alters the

alloy-composition profile (such as the spatial profile of the Al-mole fraction along the QW growth axis) across the QW structure. In addition, the interdiffusion rate can be controlled by the techniques of impurity-induced disordering [3] and impurity-free vacancy interdiffusion.² The optical properties of the quantum well, such as absorption and refractive index, can be modified by the process of interdiffusion (due to band structure changes) so that it provides the ability to tune the operating wavelengths, reduce the power consumption, and increase the switching time of photonic devices. It is also possible to confine photons between layers of as-grown and interdiffused QW's which have different refractive indexes, which is due to the fact [4] that both the band-gap and subband structure of the III–V semiconductor QW are a nonlinear function of the averaged alloy composition. This latter ability to guide light both laterally and vertically in a planar structure is crucial to the monolithic integration technology of optoelectronic integrated circuits and has been demonstrated individually, using selective interdiffusion, in discrete devices, such as lasers [5], waveguides [6], and modulators [7] with some success. However, the modified electronic and optical properties due to this nonsquare well shape are not yet fully understood.

Recent theoretical studies on the interdiffused QW structures consist of the following.

- 1) Single QW with infinitely thick barriers: two confinement profiles have been used, one being the error function that was proposed originally to study the interdiffused AlGaAs–GaAs QW band-gap in photoluminescence experiments [8], [9]. The error-function profile is determined from a one-dimension interdiffusion model with a constant interdiffusion coefficient and is used to solve for the lowest subband-edge energy by a variation method with simple trial wavefunctions and without the excitonic effects. Since then, extensive modeling of the subband structures and density of states has been calculated using a finite difference method [10] which has been applied to study the optical properties of interdiffused QW's, including excitons [11]–[15]. The other profile studied is a modified hyperbolic-function approximation where the confined eigenstates are solved

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¹It should be noted that in the literature the QW material modified by thermal interdiffusion with or without the introduction of intentional impurities is synonymously termed as "mixing" and "disordering."

²This is sometimes known as "bowing" in the literature.

analytically [16], [17]. Although this model is limited to exclude the very early stages of interdiffusion, it has the advantage that it can handle many subbands such as introduced by interdiffusion and has been applied to determine the optical properties of interdiffused QW's [18].

- 2) Single QW with finite-thickness barriers: this is a resonance-tunneling type of structure and is therefore ideal for solving the transmission tunneling method. This structure has been used for the calculation of interband and intersubband transitions in interdiffused QW's [19]–[22]. The tunneling method has the advantage of being convenient for the determination of the electric-field-induced absorption broadening and carrier tunneling time.
- 3) Multiple QW (MQW) and superlattice structures: in addition to an earlier study of the ground-state energy of a superlattice structure [23], there is a more recent report using a five-period MQW of equal as-grown well and barrier widths of 60 Å to study the refractive index around the band-edge [24]. In the latter paper, the experimental fit was reasonably good and nonparabolic band structure was considered for the calculation of subbands, although the properties of subband due to the MQW structure, such as interwell coupling were not discussed. The effects of cladding layer were not considered by either of the above studies. To date, there have been no reports of the subband properties of interdiffused MQW structures which is crucial to the understanding of the operation of optoelectronic devices and how to optimize their performance. Interdiffusion in strain layer QW's is also of interests but is not considered here.

In terms of the effect and process of interdiffusion on device impact, in particular to how modulator performance changes, it is also expected that the interdiffused (DF)-MQW structure can serve as a high-performance FP modulator (vertical cavity) by improving the change of reflectance, ΔR , and the relative reflectance change, $\Delta R/R$, (otherwise known as the fraction of reflectance change) as well as reducing its residual loss in the OFF-state and power consumption. Since only a simple thermal annealing is required for modifying the MQW structure, it becomes a very attractive technology to produce a FP modulator which can tune to operate at a precise operation wavelength λ_{op} . So the DF-MQW FP-modulator is expected to become a significant candidate in the vertical optoelectronics-integration technology. Together with the development of coplanar monolithic integration, a three-dimensional (3-D) optoelectronics integration circuit may become a reality in the near future. On the other hand, for the longitudinal type of waveguide-modulator, the electrooptic effect of DF-MQW's can provide a larger variation in Δn_{max} with a smaller field while a stronger and an almost constant Δn_{max} with a larger field. The phase-modulation properties due to these effects in the DF-MQW's suggest some types of multiwavelength application can be realized by means of fabricating planar integrated multisection waveguide-type modulators and detectors on a single substrate through the technique of selective-area

interdiffusion. However, care must be taken in the DF-MQW design, such to choose the best interdiffusion length and electric field. In fact, the DF-MQW can provide large electro-absorption and less chirping in certain selected ranges of wavelengths. These make the DF-MQW's become competitive as an electro-absorptive modulator. In addition, the performance of these DF-MQW devices may be further improved by optimizing the DF-MQW structure together with the use of strain-layered MQW materials. The above attraction stimulates the present study since the precise electronic and optical properties of the DF-MQW must be known before good performing devices can be realized.

In this paper, we report on the comprehensive modeling and detail analysis of the effect of interdiffusion on AlGaAs–GaAs MQW subband-edge eigenstates, including well-to-well coupling and the effect of cladding layers. The effect of interdiffusion on the modified property of the eigenstate is important for optical transitions of the interdiffused MQW, such as interband absorption, which are also presented here. In this work, all of the confined eigenstates of $Al_{0.3}Ga_{0.7}As$ –GaAs interdiffused MQW are calculated at room temperature for the structure comprising an intrinsic MQW core region, which consists of 10 wells and nine barriers (each with a 100-Å as-grown width) clad between infinitely thick $Al_{0.3}Ga_{0.7}As$ layer for different extents of the interdiffusion process. This type of structure is chosen because it is typical of the MQW structures currently used in waveguides and modulators. However, the interdiffusion effect on the eigenstate properties of the AlGaAs–GaAs MQW analyzed here should be applicable in general to other unstrained material systems.

The paper is arranged as follows. The interdiffusion model for the MQW is presented in Section II together with the band-edge calculation and valence band-mixing scheme. The dielectric-function approach is used here for the calculation of the polarized absorption coefficients. This is followed by presentation of numerical results in Section III which are generated for a specific as-grown MQW structure as a function of the extent of interdiffusion. A detailed analysis of the confinement profile, eigenstates, and their absorption coefficients is also included. This is followed by a quantitative estimate of how modulator performance changes with the amount of interdiffusion. Finally, conclusions are presented.

II. MODEL FORMULATION

In this work, the interdiffusion process to be considered, is based on post-growth thermal-induced interdiffusion of the two excess alloy species across all the heterointerfaces in the MQW structure under stoichiometric conditions, i.e., the Ga and Al atoms in the GaAs well and AlGaAs barrier layers, respectively, in the AlGaAs–GaAs MQW. The interdiffusion is modeled here using Fick's law with an equal and constant interdiffusion coefficient for the two interdiffusing species [25]. The extent of the interdiffusion is characterized by an interdiffusion length $L_d = (Dt)^{1/2}$, where D and t are the interdiffusion coefficient and time, respectively.³ The square of

³It should be noted here that the definition of L_d varies in the literature; for instance, some authors define L_d as $2(Dt)^{1/2}$ [9], i.e., $L_d^2 = 2$ variance

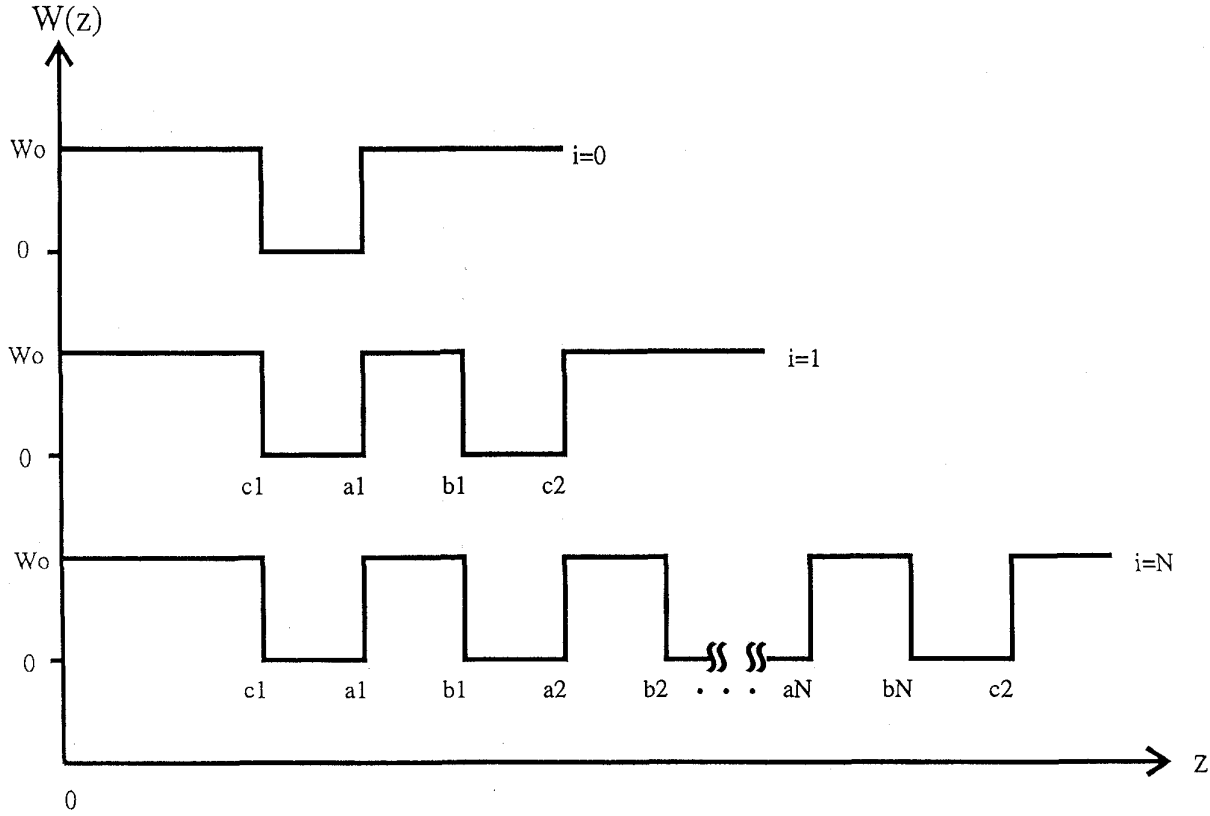


Fig. 1. Schematic illustration of the coordinates used in (1) for the MQW structures.

this length represents half of the variance of the interdiffusion distribution in a linear flow situation (i.e., $L_d^2 = \frac{1}{2}$ variance, and $L_d = \text{standard deviation}/\sqrt{2}$). The superposition principle is assumed for all of the layers considered in the structure, which includes the MQW core layers and the infinitely thick cladding layers. This is a useful and realistic model for the interdiffusion process in the AlGaAs–GaAs material system. The effects of impurities are not considered here specifically for simplicity, although they are known to enhance the rate of interdiffusion and hence produce an effectively larger L_d for the same annealing time. However, since the purpose of the present study is to determine the effects of interdiffusion-induced nonsquare confinement profile, with respect to a different L_d , on the properties of MQW structures, this approach is adequate. The Al composition profile $w(z)$ as a function of L_d is given by

$$w(z) = \frac{w_0}{2} \left\{ 2 - \operatorname{erf}\left(\frac{z - c_1}{2L_d}\right) + \operatorname{erf}\left(\frac{z - c_2}{2L_d}\right) + \sum_{i=1}^N \left[\operatorname{erf}\left(\frac{z - a_i}{2L_d}\right) - \operatorname{erf}\left(\frac{z - b_i}{2L_d}\right) \right] \right\} \quad (1)$$

where w_0 is the as-grown Al concentration in the barrier and the cladding layer, N is the number of barriers within the MQW core of the as-grown structure, $\operatorname{erf}(y)$ denotes the error function, $z \geq 0$ is the growth axis of the MQW layers where and $L_d = \sqrt{2}$ standard deviations.

the MQW structure is positioned on the positive side, a_i and b_i are the left and right interface positions, respectively, of the i th as-grown barrier within the MQW core, while c_1 and c_2 are that at the two end positions of the as-grown MQW core (i.e., interface between the cladding and core layers), which are shown in Fig. 1. The advantage of using the expression in (1) to describe the interdiffusion-induced nonsquare profile is its ability to model different MQW structures with any number of periods, different widths and heights of the well and barrier layers, as well as different cladding layers, by adjusting the terms involving c_1 and c_2 . In (1), the omitted $i = 0$ case represents a single QW with thick AlGaAs cladding layers, $i = \text{odd (even)}$ represents an even (odd) number of wells in the MQW core with an Al concentration of w_0 in the cladding layer, as shown in Fig. 1. For cases which use GaAs cladding layers, such as the resonant-tunneling structures, (1) can still be used when the constant has a value of 2, when terms consist of c_1 and c_2 are dropped, and take $N \geq 2$; although this versatility is also demonstrated in a Green's function model [26], (1) is an analytical expression and no numerical integration is necessary. The MQW confinement profile is obtained from $w(z)$ by a method similar to the case of a single QW [10] and is briefly described here.

The diffused Al composition profile defined by (1) is used to obtain the interdiffused QW parameters including bandgap, $E_g(z) = E_g(w(z))$, and well depth, $\Delta E_r(L_d) = Q_r[E_g(z_1) - E_g(z_2)]$, where the subscript r denotes either the electron in the conduction band (C) or heavy or light holes

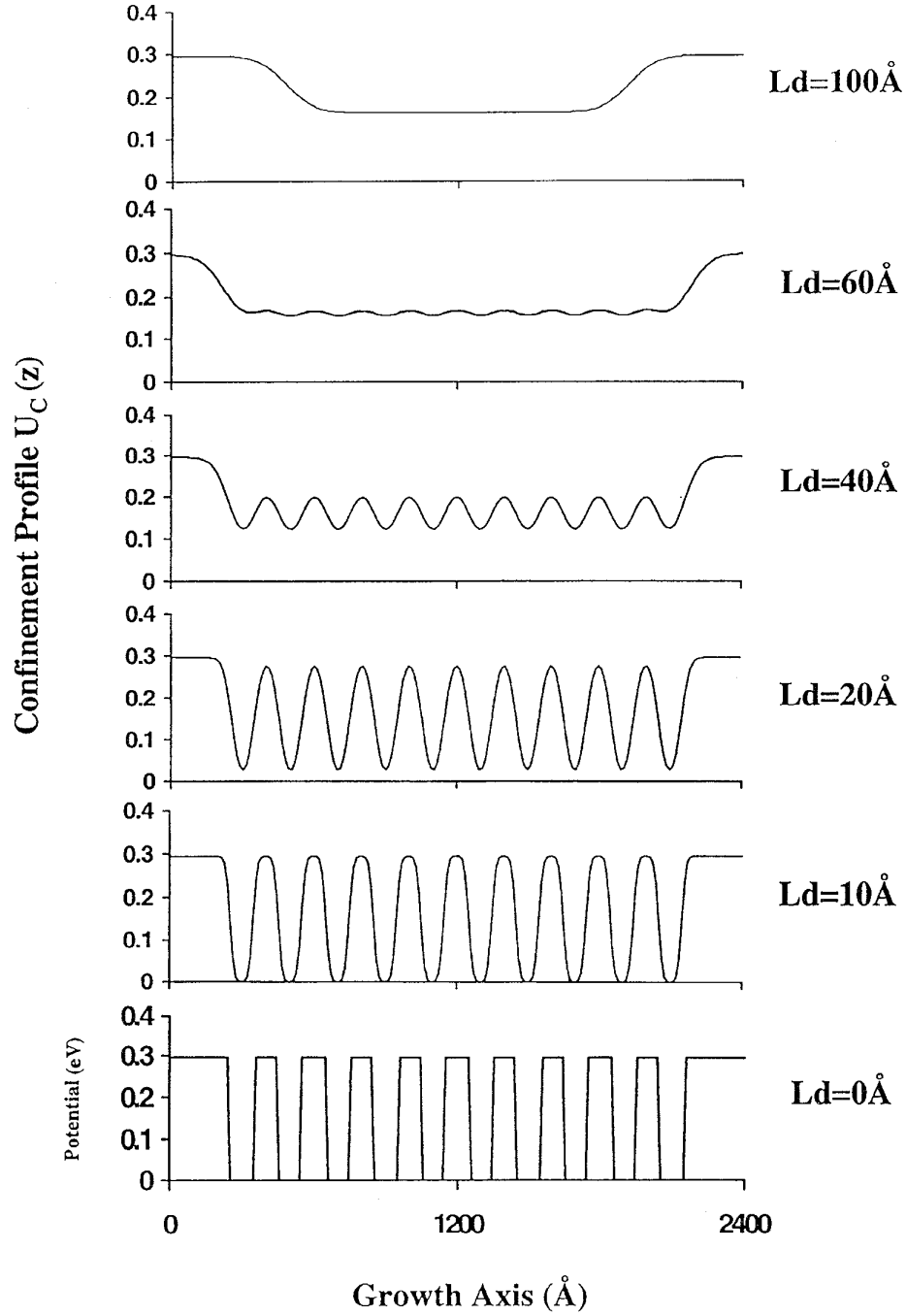


Fig. 2. The electron confinement potential for the AlGaAs-GaAs MQW ($w_0 = 0.3$, $L_z = L_b = 100$ Å) with several values of L_d .

in the valence band ($V = H$ or L), Q_r is the band offset splitting, and z_1 and z_2 refer to the positions corresponding to top of the barrier and bottom of the well, respectively. The interdiffused MQW confinement profile, $U_r(z)$, is defined as $U_r(z) = Q_r[E_g(w(z)) - E_g(w = 0)]$. The convention here is to define zero potential to be both at the bottom of the as-grown square MQW and positively up in both bands.

The QW subband edge at the zone-center of Γ_6 -valley symmetry can be calculated separately for electrons and holes, using the Ben-Daniel and Duke model [27]. A z -position

dependent effective mass determined by the interdiffused composition profile is used in the one-dimensional Schrödinger-like equation, for the envelope function $\psi_{r\ell}(z)$, which is written as

$$-\frac{\hbar^2}{2} \frac{d}{dz} \left[\frac{1}{m_{\perp r}^*(z)} \frac{d\psi_{r\ell}(z)}{dz} \right] + U_r(z)\psi_{r\ell}(z) = E_{r\ell}\psi_{r\ell}(z) \quad (2)$$

where $\ell = 1, 2, \dots$ are the pure MQW subband levels for either the electrons ($C\ell$) or holes ($V\ell$), respectively; these

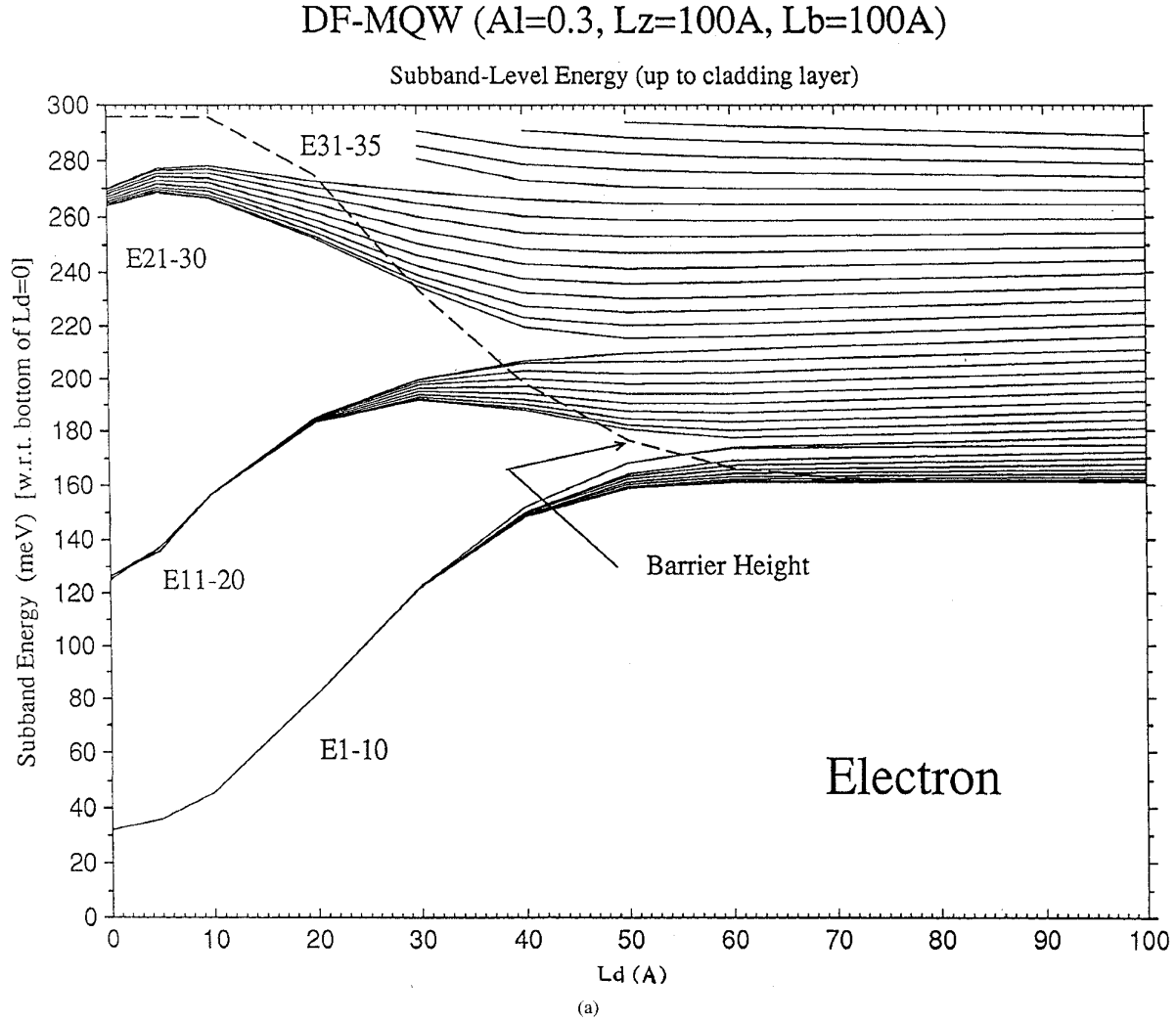


Fig. 3. The subband-edge eigenstate energy of the DF-MQW ($w_0 = 0.3$, $L_z = L_b = 100 \text{ \AA}$) as a function of L_d for (a) electron, (b) heavy hole, and (c) light hole. The dashed line indicates the height of barriers in the MQW core with zero taken from the bottom of the as-grown ($L_d = 0$) well. The energy levels are arranged in total number counting from the lowest level.

pure sublevels (ℓ) are due to the confinement effect only, where well-to-well coupling is ignored, i.e., as if they are single wells; $m_{\perp r}^*(w(z))$ is the carrier effective mass in the z direction which is perpendicular to the QW layers; $E_{r\ell}$ is the subband-edge energy, and the zero energy is taken to be at the bottom of the as-grown MQW. The eigenvalue problem, (2), is solved numerically for the entire MQW structure using a finite-difference method with the boundary conditions taken to be zero at the end of a cladding layer of finite thickness, i.e., $\psi_{r\ell}(0) = \psi_{r\ell}(L_f) = 0$, where $L_f = NL_b + (N+1)L_z + 2L_c$ (L_c is the cladding layer width), i.e., the MQW core and cladding are embedded in a well of width L_f with an infinitely high barrier to represent the infinitely thick cladding layer. This method permits all the subband eigenstates to be determined, including those due to well-to-well coupling.

The other standard methods of calculation for the MQW eigenstates are tight-binding [32] and transmission tunneling [23]. The former method takes into account the pre-assumption of some well-to-well coupling with an approximate coupling

strength of the ground states which introduces inaccuracy in cases of strong coupling. It also ignores coupling of the upper states. The latter model becomes inaccurate in thick multilayered structures and inapplicable in the case of thick barriers.

In order to calculate the absorption coefficient accurately, the nonparabolic band-structure dispersion along the transverse x - y direction of the QW structure is required. The valence-subband dispersion for the mixing between heavy- and light-hole states (denoted by $V = H$ and $V = L$, respectively) are considered here for the transverse (parallel to QW layers) wave vector $\|k_{xy}\| = k_{\parallel} = 0$, which can be solved in the neighborhood of a high-symmetry zone-center (i.e., $k_{\parallel} = 0$) using approximation methods such as the one developed previously using an effective Hamiltonian [28]. This approach has been applied in single DFQW structures [15] and is based on the analogous application of the $k \cdot p$ method to the subbands. The mixed envelope function in the valence-band, $\Psi_V(k_t, z)$, at any finite k_t not too far away from the

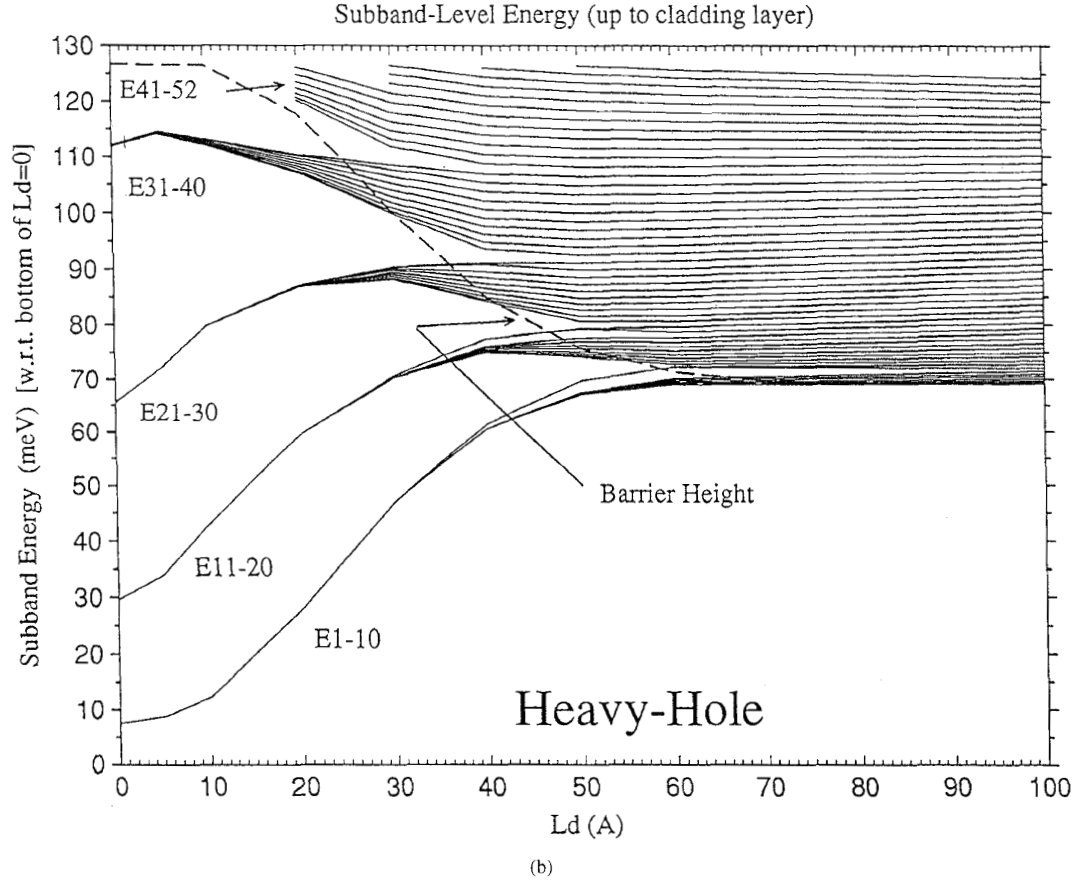
DF-MQW ($A_l=0.3$, $L_z=100\text{\AA}$, $L_b=100\text{\AA}$)

Fig. 3. (Continued.) The subband-edge eigenstate energy of the DF-MQW ($w_0 = 0.3$, $L_z = L_b = 100\text{\AA}$) as a function of L_d for (b) heavy hole. The dashed line indicates the height of barriers in the MQW core with zero taken from the bottom of the as-grown ($L_d = 0$) well. The energy levels are arranged in total number counting from the lowest level.

highest symmetry point ($k_{\parallel} = 0$) can be expressed as a linear combination of the degenerate envelope functions $\psi_{V\ell}(z)$ without mixing at $k_{\parallel} = 0$, which are obtained *a priori* from the solution of (2). The validity of the approximation is dependent upon a limited range of k_{\parallel} , since only a finite-dimension basis set for the expansion is used in practice. However, a small range of k_{\parallel} near 0 is sufficient for the interband transitions around the absorption edge, where the QW effects are most significant. The basis for the expansion is defined as

$$\Psi(k_{\parallel}, z) = \sum_{\ell=1}^N \sum_{V=H,L} d_{V,\ell}(k_{\parallel}) \psi_{V,\ell}(z) \quad (3)$$

where d is the expansion coefficient, V includes the lifted fourfold degenerate-hole states, and N is the maximum number of bases taken in each V , which includes all subbands. The effective Hamiltonian is

$$\begin{bmatrix} E_{+H} & C & B & 0 \\ C^* & E_{-L} & 0 & B^T \\ B^* & 0 & E_{+L} & C^T \\ 0 & B^* & C^* & E_{-H} \end{bmatrix} \quad (4)$$

where

$$\begin{aligned} B_{\ell\ell'} &= \sqrt{3} \frac{\hbar^2}{m_0} \gamma_2(-k_x - ik_y) \int_0^{L_f} dz - \psi_{H\ell}(z) \frac{\partial}{\partial z} \psi_{L\ell'}(z) \\ C_{\ell\ell'} &= \frac{\sqrt{3}}{2} \frac{\hbar^2}{m_0} \gamma_2(k_x - ik_y)^2 \int_0^{L_f} dz - \psi_{H\ell}(z) \psi_{L\ell'}(z) \\ E_{\pm H} &= \left[E_{\pm H\ell} - \frac{\hbar^2}{2m_{\parallel H}} k_{\parallel}^2 \right] \delta_{\ell\ell'} \\ E_{\pm L} &= \left[E_{\pm L\ell} - \frac{\hbar^2}{2m_{\parallel L}} k_{\parallel}^2 \right] \delta_{\ell\ell'} \end{aligned}$$

where $\gamma_2(\omega)$ is the Luttinger parameter, the sign $\pm H, L$ stands for spins, ℓ and ℓ' also represent an index for different entry in the matrix, δ denotes the delta function at $\ell - \ell'$ which represents the diagonal terms, and L_f is defined earlier. The effect of the introduction of this larger well is to determine numerically the continuum levels above the top of the DF-MQW. It should be noted that, in the absence of an applied electric field or any other mechanism that will distort the inversion symmetry assumed here, the symmetric MQW confinement-potential profile causes the valence subband to exhibit a twofold Kramer's spin degeneracy.

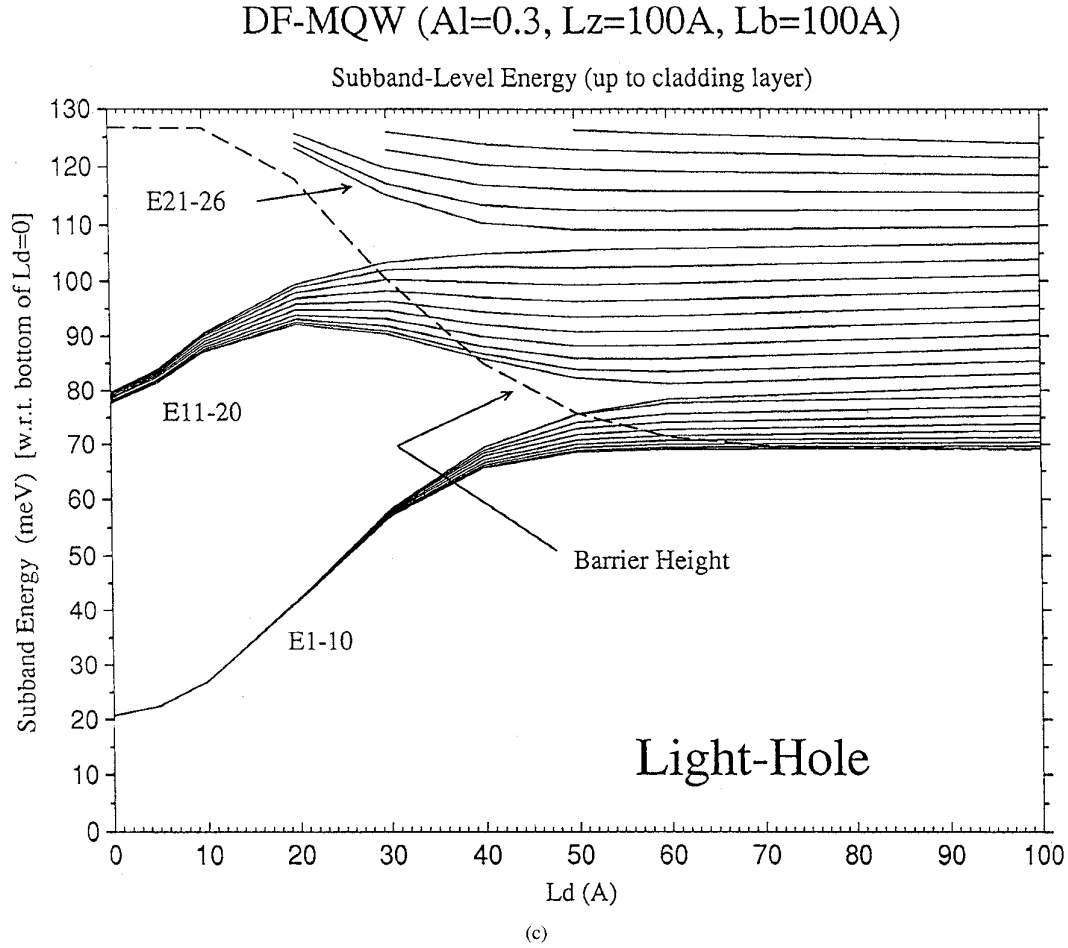


Fig. 3. (Continued.) The subband-edge eigenstate energy of the DF-MQW ($w_0 = 0.3$, $L_z = L_b = 100 \text{ \AA}$) as a function of L_d for (c) light hole. The dashed line indicates the height of barriers in the MQW core with zero taken from the bottom of the as-grown ($L_d = 0$) well. The energy levels are arranged in total number counting from the lowest level.

The interband transitions are considered here without the electron-hole coulomb interaction. The omission of this excitonic effect can introduce inaccuracy at the band-edge in certain QW cases, such as those of an undoped structure, of high-purity material and operation at low temperatures. Thus, the present formulation demonstrates a somewhat simplified absorption-coefficient calculation without the exciton resonance at the absorption edge which may be unresolved even after interdiffusion. However, these bare transition states are the long-range exciton-continuum states and serve as a background to the absorption coefficient. It should be noted that in the case of the optical properties of an MQW laser structure, where excitons are not important, the present formulation of the imaginary part of the dielectric function is of importance.

Once the electron and hole-envelope wavefunctions and subband energy levels of the DF-MQW structure have been determined, the linear absorption coefficient $\alpha(\omega)$ may be determined in terms of the imaginary part of the dielectric function $\varepsilon_2(\omega)$ using the relation [29]

$$\alpha(\omega) = \frac{\omega \varepsilon_2(\omega)}{c_0 n_R(\omega)} \quad (5)$$

where $n_R(\omega)$ and c_0 are the refractive index of the QW and the velocity of light in vacuo, respectively. The incident electromagnetic radiation is assumed to propagate parallel to the x - y plane (perpendicular to z axis) of the QW layer, therefore α and ε_2 are anisotropic with polarization (TE and TM) [33]. Since we are interested in the QW quantization effect which manifests itself over a limited energy range above the bandgap, we use a $\varepsilon_2(\omega)$ calculation, which is based on the direct interband transitions around the absorption edge in the Γ valley and an additional factor to take account of the polarization. ε_2 is expressed as

$$\varepsilon_2^{\text{TE,TM}}(\omega) = \frac{e^2 M_b^2 \wp}{\pi \varepsilon_0 m_0^2 \omega^2 L_z} \sum_{\ell, \ell'} \int dk |\langle \psi_{C\ell} | \psi_{V\ell'} \rangle|^2 \cdot \mathcal{L}(E_{C\ell}(k_{\parallel}) - E_{V\ell'}(k_{\parallel}) - \hbar\omega) \quad (6)$$

where ε_0 is the permittivity of free space, e and m_0 are the electron charge and rest mass, respectively, $M_b^2 = m_0^2 P^2 / 3\hbar$ and P are given by Kane's model, \mathcal{L} is the Lorentzian broadening factor with half-width-half-maximum Γ_b , the summation in (6) is over all the subband and minisubband bound and continuum states in both bands, and \wp is the polarization

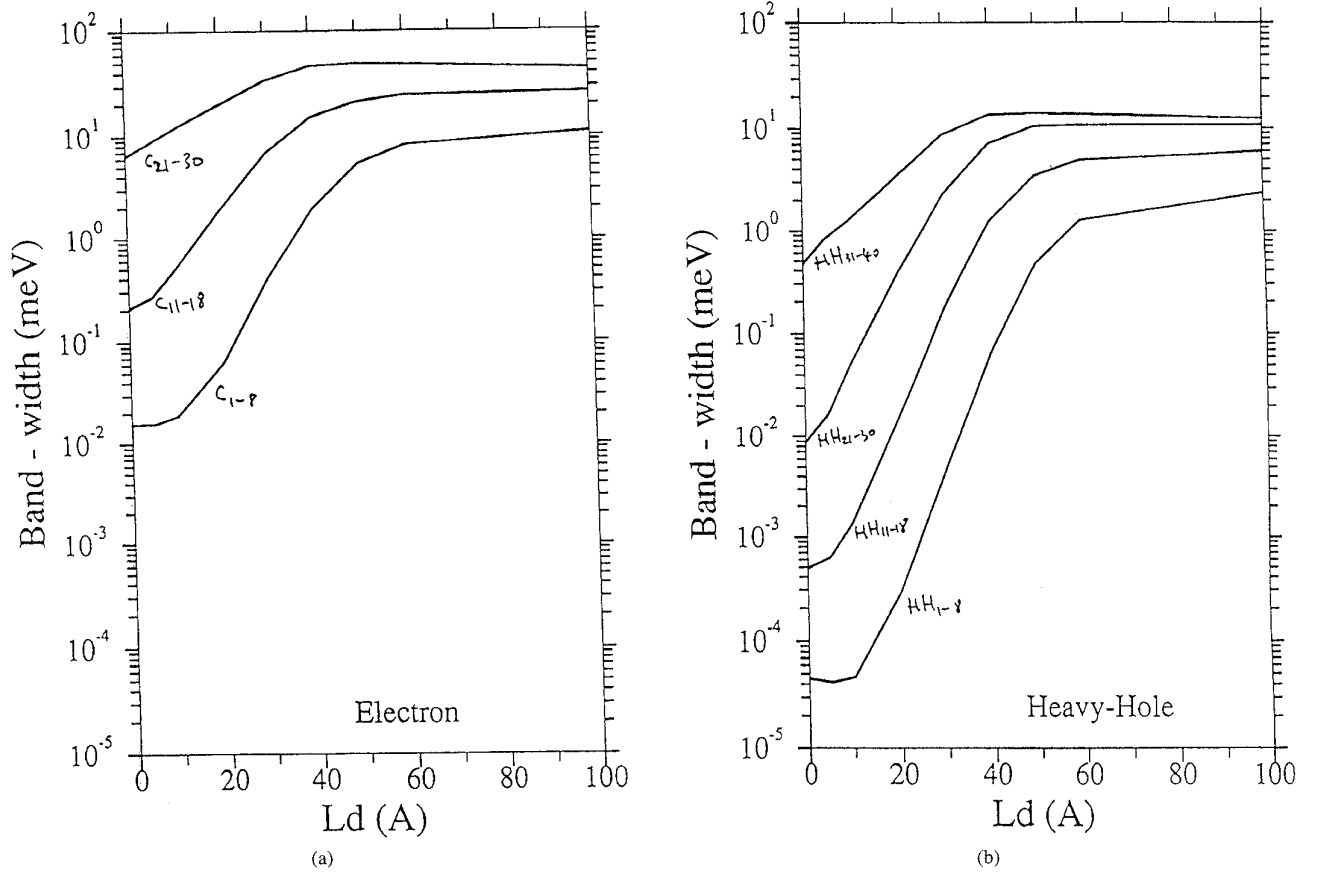


Fig. 4. Band-width of the minisubbands in log scale as a function of L_d for (a) electron and (b) heavy-hole.

TABLE I
MATERIAL PARAMETER FOR AlGaAs-GaAs QW

	Al _w Ga _{1-w} As/GaAs	Units	Ref.
$Q_C : Q_V$	0.7 : 0.3	--	38
$E_g(w)$	$1.424 + 1.594w + w(1-w)(0.127-1.31w)$	eV	39
$\Delta_0(w)$	$0.34 - 0.04w$	eV	40
$\gamma_z(w)$	$2.02 - 1.12w$	m_0	41
$m_c(w)$	$0.0665 + 0.0835w$	m_0	41
$m_{\perp H}^*(w)$	$0.33 + 0.18w$	m_0	41
$m_{\perp L}^*(w)$	$0.09 + 0.09w$	m_0	41
$m_{\parallel H}^*(w)$	$0.11 + 0.10w$	m_0	41
$m_{\parallel L}^*(w)$	$0.20 + 0.15w$	m_0	41
Γ_b	5	meV	42

m_0 and ϵ_0 are the electron mass and static dielectric constant, respectively, in free space.

factor at the band-edge where $\phi^{\text{TE}} = 3/2(HH), 1/2(LH)$ and $\phi^{\text{TM}} = 0(HH), 2(LH)$.

III. RESULTS AND DISCUSSION

The MQW structure analyzed here consisted of 10 wells and nine barriers in the core region of Al_wGa_{1-w}As - GaAs materials system and two finite cladding layers of Al_wGa_{1-w}As, both of the same Al concentration, where the as-grown structural parameters are $w = w_0 = 0.3$, $L_z = 100$ Å, $L_b = 100$ Å, and $L_c = 600$ Å (thus $L_f = 3100$ Å), and the other material parameters are given in Table I. The discussion

below is based on this structure unless otherwise specified. In this study, the effect of interdiffusion on the MQW is based on the modification of the confinement profile, eigen-energy, eigen-wavefunctions, well-coupling band-width, and interband optical transitions by varying the interdiffusion length L_d .

A. Confinement Profile

The electron-confinement profile is shown in Fig. 2 for several values of L_d . It can be seen that $U_C(z)$ changes gradually from an as-grown square ($L_d = 0$) to a nonlinear shape initially ($0 \leq L_d < 20$ Å) while retaining the magnitude

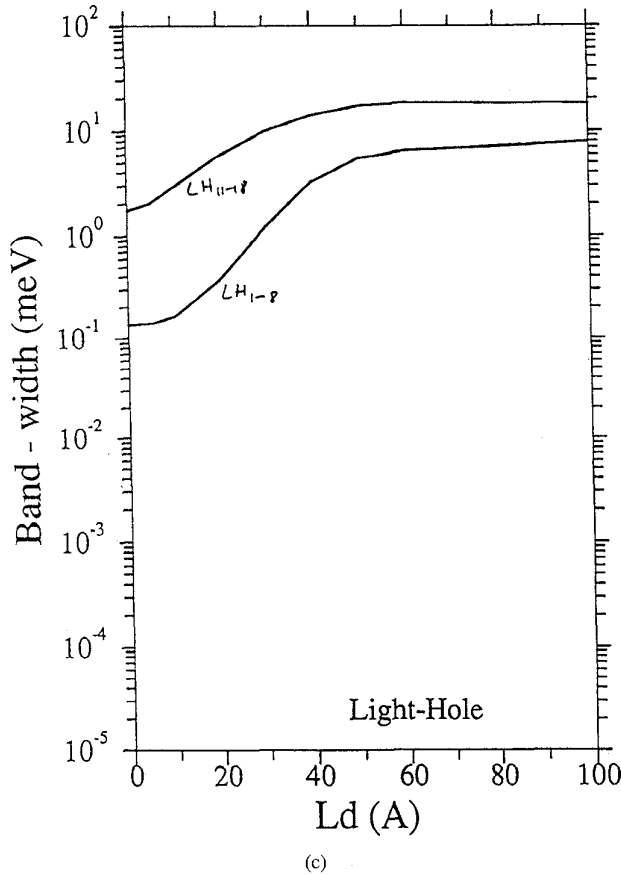


Fig. 4. (Continued.) Band-width of the minisubbands in log scale as a function of L_d for (c) light-hole.

of its confinement depth $\Delta E_C(L_d)$, and as $L_d \geq 20$ Å, the QW depth starts to reduce and becomes zero at $L_d = 100$ Å. The mid-point of the confinement depth (potential at $\frac{1}{2}\Delta E_C$), which represents the average of the well and barrier potential due to interdiffusion, gradually moves toward a potential which corresponds to the average Al composition between the well and barrier, i.e., $w = 0.15$. After extensive interdiffusion between the well and barrier (i.e., $L_d = 100$ Å here) their Al content should be averaged out (i.e., $\frac{1}{2}(0 + 0.3) = 0.15$ in our case). However, it should be noted that due to "bowing," the corresponding potential in the core region is not the simple average between the well and the barrier potentials (i.e., $U_C(L_d = 100 \text{ Å}) \neq \frac{1}{2}U_C(L_d = 0) = 147.819 \text{ meV}$). In fact, this average potential is $U_C = 0.7[E_g(w = 0.5) - E_g(0)] = 161.1671 \text{ meV}$ (see Fig. 2). The analysis for the hole is similar to that of the above with $U_V(L_d = 100 \text{ Å}) = 69.073 \text{ meV}$ and $\frac{1}{2}U_V(L_d = 0) = 63.351 \text{ meV}$. The confinement profile now becomes that of a wide single QW with graded-interfaces and with the two cladding layers, which act as the only barriers, and the entire core region acts as the well. This is the intermediate stage of interdiffusion for a MQW structure with nonzero cladding height (such as AlGaAs) and for which bandgap remains stable (constant E_g) within this range, especially in the central core region. Beyond $L_d = 100$ Å, the interdiffusion results in a graded profile for the Al

composition (nonconstant E_g) across the entire core region until the thick cladding layers start to affect the complete composition profile. Eventually, $w(z)$ approaches an average constant value between the initially averaged core composition and that of the cladding layers, if it has a finite thickness. On the other hand, in the case of an infinite-thickness cladding layer, the core Al composition will approach that of the as-grown cladding layer as $L_d \rightarrow \infty$.

B. Subband-Edge Eigenstates

In order to discuss the eigenstate results of the interdiffused MQW structure considered here, it will be helpful to define an additional system of labeling. The eigenstates of a single QW are in fact the so-called edge (minima) of the subbands, which arise due to the splitting of the bulk bands caused by quantum confinement. These eigenstates are labeled by an index $\ell = 1, 2, \dots$ to denote their corresponding energy levels and wavefunctions, see (2). However, when N_w identical wells are constructed in a MQW structure, each eigenstate of the individual well that belongs to the same subband are coupled together to form a mini-band of their own. The states within these mini-bands are now denoted by a second index $\xi = 1, 2, \dots, N_w$, so that the energy and wavefunction of an eigenstate are written as $E_{r\ell,\xi}$ and $\psi_{r\ell,\xi}$, respectively, where for instance $E_{C2,4}$ and $\psi_{C2,4}$ refer to the fourth eigenstate within the mini-band of the second subband. It should be noted that $N_w = 1$ refers to a single QW, while a degenerate $E_{r\ell,\xi}$ (for all ξ) is considered to be the case for weak or insignificant well-to-well coupling.

Fig. 3 shows the eigenstate energy for three cases of electron, heavy, and light holes with respect to the bottom of the as-grown QW (i.e., the bulk GaAs band-edge in the present case). These states are grouped in tens due to the mini-band of 10 eigenstates that arise from the 10 QW's considered here. The energy of the barrier height U_b , which is also measured with respect to the GaAs edge at the center of the MQW structure, is indicated by a dash-line. It can be seen that as interdiffusion starts ($L_d < 20$ Å), there are three electron, four heavy-hole, and two light-hole degenerate subbands, where the degeneracy of all the respective top subbands are slightly raised, which is a consequence of the weaker confinement near the top of the well. As interdiffusion proceeds further, the lifting of this degeneracy increases and it turns into a mini-band in all three cases, where the higher energy and lighter mass subbands are enhanced more significantly, which is due in general to their weaker confinement. The splitting of the degenerate levels becomes evenly spaced and fully distributed throughout all the subbands in all cases as the interdiffusion proceeds far enough so that the subbands are above the barrier energy U_b , as indicated in the region above the dash-line. These states can now be considered as bulk-like states, since they are now in a single QW within an as-grown width of $10L_z + 9L_b = 1900$ Å. However, as it can be seen for subbands near and above U_b , the mini-band nature remains because the states are affected by the slightly modulated MQW structure; it behaves like the transmission-scattering states above a nonflat surface. Also, there are a number of states introduced at the top of the MQW core structure, due to interdiffusion, which

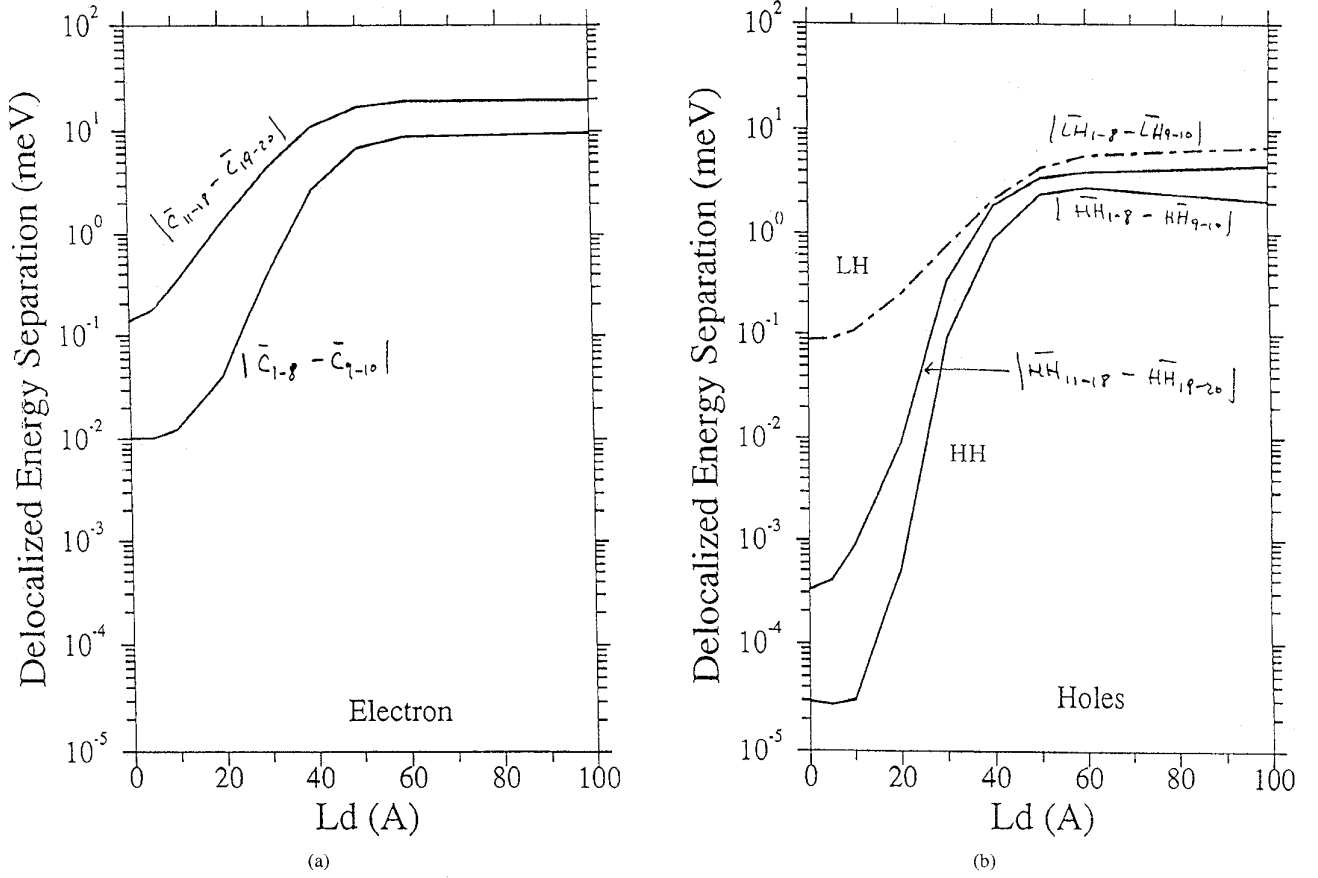


Fig. 5. The delocalization energy separation between the center MQW core localized wavefunctions and that at the far ends near the cladding layers. (a) Electron and (b) heavy-hole.

are the $C(\ell = 4; 1 \leq \xi \leq 5)$, $HH(\ell = 5; 1 \leq \xi \leq 10)$ and $(\ell = 6; 1 \leq \xi \leq 2)$, and $LH(\ell = 3; 1 \leq \xi \leq 6)$, and in fact an increasing number of states will be pulled down and from the continuum and become confined near the top of the MQW core as L_d is increased further until eventually the MQW core merges with the cladding layers and becomes an averaged bulk material.

The lifting of the degeneracy is due to the tunneling of the confined carriers into the neighboring wells and causes an increase of the well-to-well coupling of the eigenstates which cause these levels to split both coherently and evenly into a mini-band. The increase of the coupling strength is a consequence of the interdiffusion which causes the barriers to become lower and narrower, thereby enabling the confined carriers to tunnel easier.

One point to note here is the increase of all the eigen-energies during the early stages of interdiffusion ($L_d < 10$ Å), where the depth of the well remains constant, as can be found from the dashed line. This means that the eigen-energy increases with L_d within this region of interdiffusion, which can be explained by the narrowing of the well for small L_d , which is also found in single interdiffused QW's [10], [31]. The reason is that the upper high-energy levels also increase, although the effective well width is wider, which is due to the fact that the confined carrier has a larger probability in the center of the symmetric QW (since ψ^2 is bell-shaped), so

that it experiences more of a narrow well in the center than a wider well near $\pm L_z/2$.

Another point worth noting is the ninth and tenth states in the first minisubband and the nineteenth and twentieth states in the second minisubband appear to group together and split away from their original group of 10 (see Fig. 3). This is due to the antisymmetry of the two wells next to the cladding barrier layer where interdiffusion on the left- and right-hand side interfaces are different, since one is due to a finite source and the other from an infinite-like source. This will become clearer later when their wavefunctions are discussed.

The mini-band width of the electron, heavy-, and light-hole subbands as a function of L_d are shown in Fig. 4(a)–(c), respectively. Note that only the first eight states ($1 \leq \xi \leq 8$) are considered here for the first and second minisubbands ($\ell = 1, 2$). It can be seen for all three cases that, as interdiffusion starts, the mini-band width increases quite rapidly until L_d reaches 50 Å, after which point they slowly level up as $L_d \rightarrow 100$ Å. There are two exceptions, one for the first HH minisubband ($\ell = 1$) at $L_d \approx 5$ Å, where the width of the band actually decreases slightly, and the other for the third and fourth subbands ($\ell = 3, 4$) of the heavy-hole and the third minisubband ($\ell = 3$) for the electron where the band-width increases to a maximum at $L_d \approx 50$ Å and then decreases slightly. The first of these can be explained by the narrowing of the wells and thus a widening of the barrier near

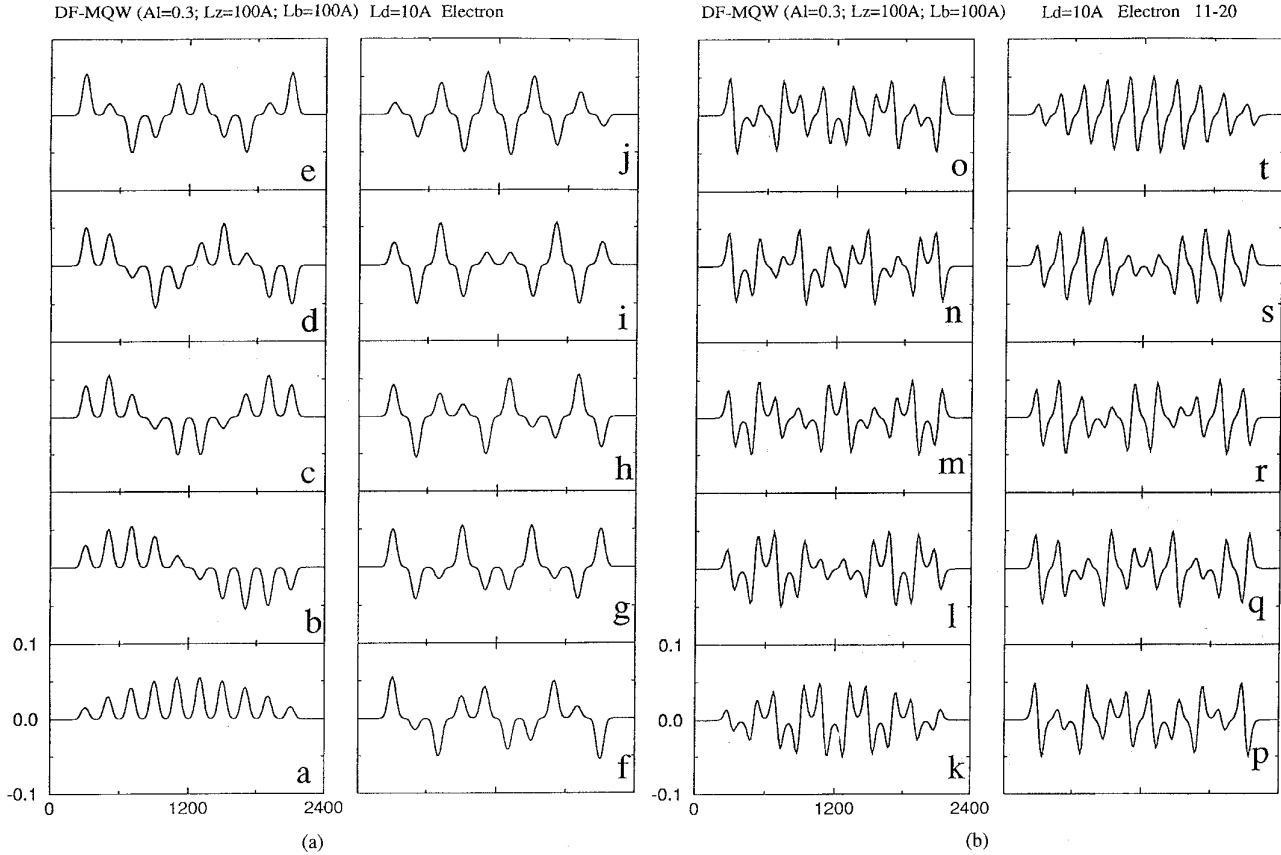


Fig. 6. The first (lowest energy) 20 eigenstates of electron for three cases where a–j denote the first 10 and k–t denote the next 10. $Al = 0.3$, $L_z = 100$ Å, and $L_b = 100$ Å for (a)–(b) $L_d = 100$ Å.

TABLE II
SUBBAND ENERGY (meV)

first mini-subband states	L_d (Å)				
	0	30	40	50	60
HH1	7.4292	47.220	60.593	67.014	68.825
HH8	7.4292	47.225	60.659	67.477	70.100
HH9	7.4292	47.316	61.505	69.670	72.264
HH10	7.4292	47.316	61.505	69.670	72.305

the bottom where the HH ($\ell = 1$) level is located, as this would reduce the well-to-well coupling for such eigenstates, therefore reducing the coupling-induced mini-band-width. The second phenomenon for the higher energy levels is due to the inclusion of the last two states ($\ell = 3; \xi = 9, 10$) and ($\ell = 4; 1 \leq \xi \leq 10$) which are not considered in the first two subbands ($\ell = 1, 2$), as these states will decouple from the rest of the lower energy states within the minisubband, since the QW's shape are no longer identical at large enough L_d 's. In fact, if we list the actual first minisubband energies for HH ($\xi = 1, 8, 9, 10$), as shown in Table II, all of the energies start at the same value for $L_d = 0$ and the energy separation between the first eight states and the last two states increases from zero to approximately 3 meV as L_d increases.

The band-widths for the first minisubband are shown in Table III with accuracy up to six decimal places of a meV. For comparison, the tight-binding method of Bastard [32] has also been used to determine this band-width. As can be seen

in Table III, the tight-binding method agrees very well with our full numerical calculation for small L_d 's except for a slight overestimation of the energy, while for larger L_d 's it underestimates the energy by a small amount. However, for the case of $L_d = 60$ Å, the tight-binding method underestimates the energy by over 25% for both cases of the lighter mass carriers, i.e., C and LH . This underestimation is due to the strong well-to-well coupling effect and band-mixing which are not fully accounted for in the tight-binding method. In spite of these problems, both methods agree quite well in general.

The delocalization effect for the two far-end QW's can be quantitatively described by a separation energy between this group of two QW's, and another group consists of the rest of the central eight QW's using the mean subband-energy positions of the respective two groups of QW's. This is defined as

$$E_D = \left| E_9 + \frac{E_{10} - E_9}{2} \right| - \left| E_1 + \frac{E_8 - E_1}{2} \right|$$

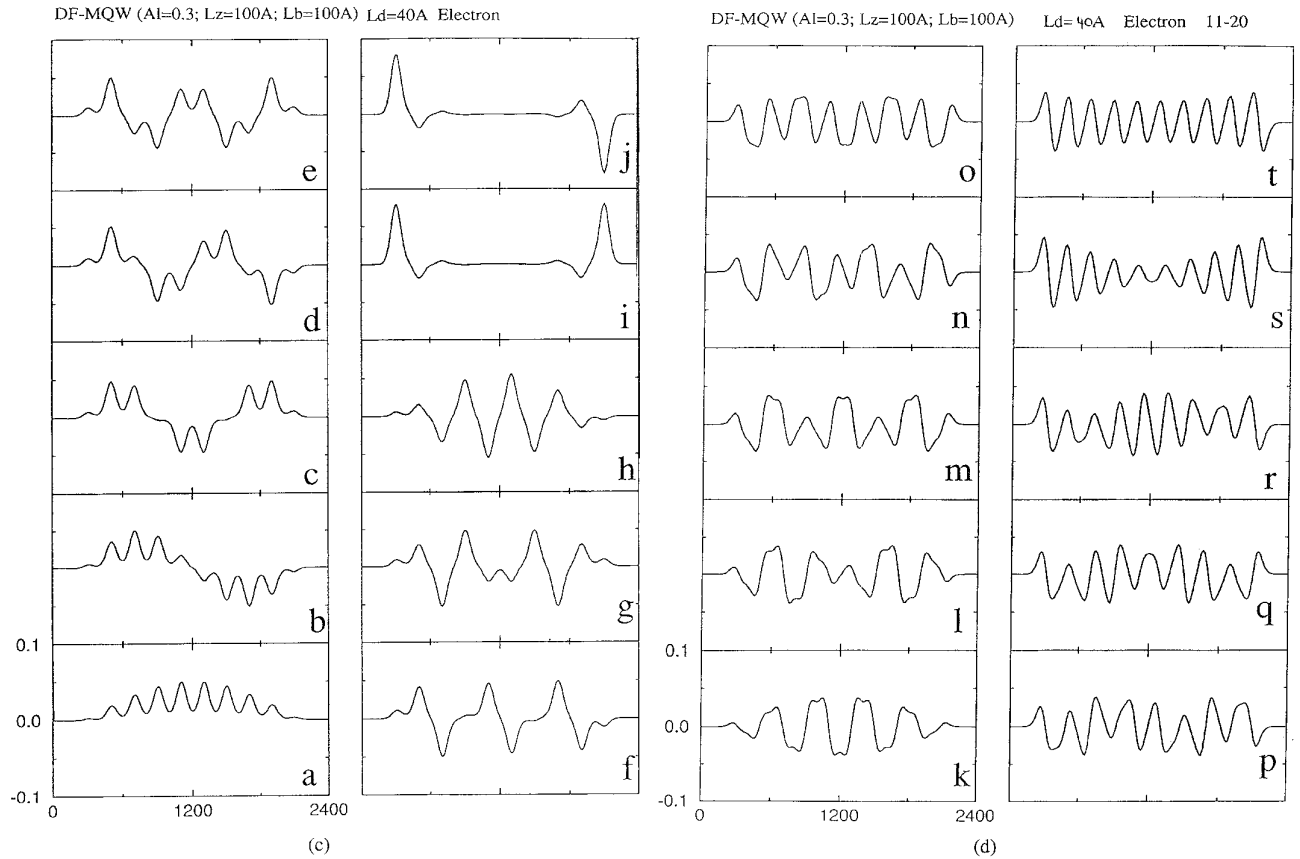


Fig. 6. (Continued.) The first (lowest energy) 20 eigenstates of electron for three cases where a-j denote the first 10 and k-t denote the next 10. $Al = 0.3$, $L_z = 100$ Å, and $L_b = 100$ Å for (c)-(d) $L_d = 40$ Å.

TABLE III
DF-MQW SUBBAND SPLITTING BAND-WIDTH (meV) FOR THE FIRST 10 EIGENSTATES

first mini-subband (10 states)		L_d (Å)							
		0	5	10	20	30	40	50	60
C	TBM	0.019290	0.019372	0.023485	0.077133	0.436239	2.082465	5.540586	6.396368
	this work	0.018509	0.018751	0.022699	0.074347	0.408824	1.951845	5.364641	8.126483
HH	TBM	0.000056	0.000050	0.000056	0.000302	0.004903	0.069714	0.492352	1.246786
	this work	0.000053	0.000050	0.000056	0.000660	0.004635	0.065599	0.462686	1.276364
LH	TBM	0.167349	0.170988	0.201441	0.461179	1.409660	3.548374	5.260472	4.027552
	this work	0.160571	0.164462	0.193652	0.373092	1.201327	3.249610	5.482772	6.479593

TBM denotes the tight-binding-method of Bastard and this work represents the full numerical calculation employed here.

for $\ell = 1$, and similarly for the other ℓ, ξ 's. Although the separation energy E_D is only based on the averaged band-edge energy position of the two QW groups, this can serve as a good indicator and measurement of well-shape change for the extreme QW's from the central group of QW's. The delocalized energy separation for the $C(\ell = 1, 2)$, $HH(\ell = 1, 2)$, and $LH(\ell = 1)$ are shown in Fig. 5(a) and (b). It can be seen that E_D clearly increases from approximately zero to an almost constant level for all cases. The separation is always smaller for the lower mini-band as the subbands are tightly confined together. A point worth noting is that for the first ($\ell = 1$) HH minisubband, E_D increases as L_d increases up to 60 Å and then slightly decreased as L_d reaches 100 Å. This

reflects the low-lying first-subband ($\ell = 1$) levels $HH9$ and $HH10$ in the far-end wells where they are still supported by a very shallow well at $L_d = 60$ Å and, as $L_d > 60$ Å, they are pushed down by the upper levels $HH(\xi > 10)$.

The subband-edge eigenstate wavefunctions also serve as a good characterization of the MQW structure after interdiffusion since it is a "sensitive" function of the change of the well shape. Fig. 6(a) and (b) show the 10 coupled wavefunctions for the first and second subbands, $C(\ell = 1, 2; 1 \leq \xi \leq 10)$, for $L_d(\text{Å}) = 10, 40$, and 60. The square QW cases are not shown here since they behave in exactly the same manner as a single isolated well due to the 100-Å-thick barriers. The coupling-mode phenomena can be observed here for most of the

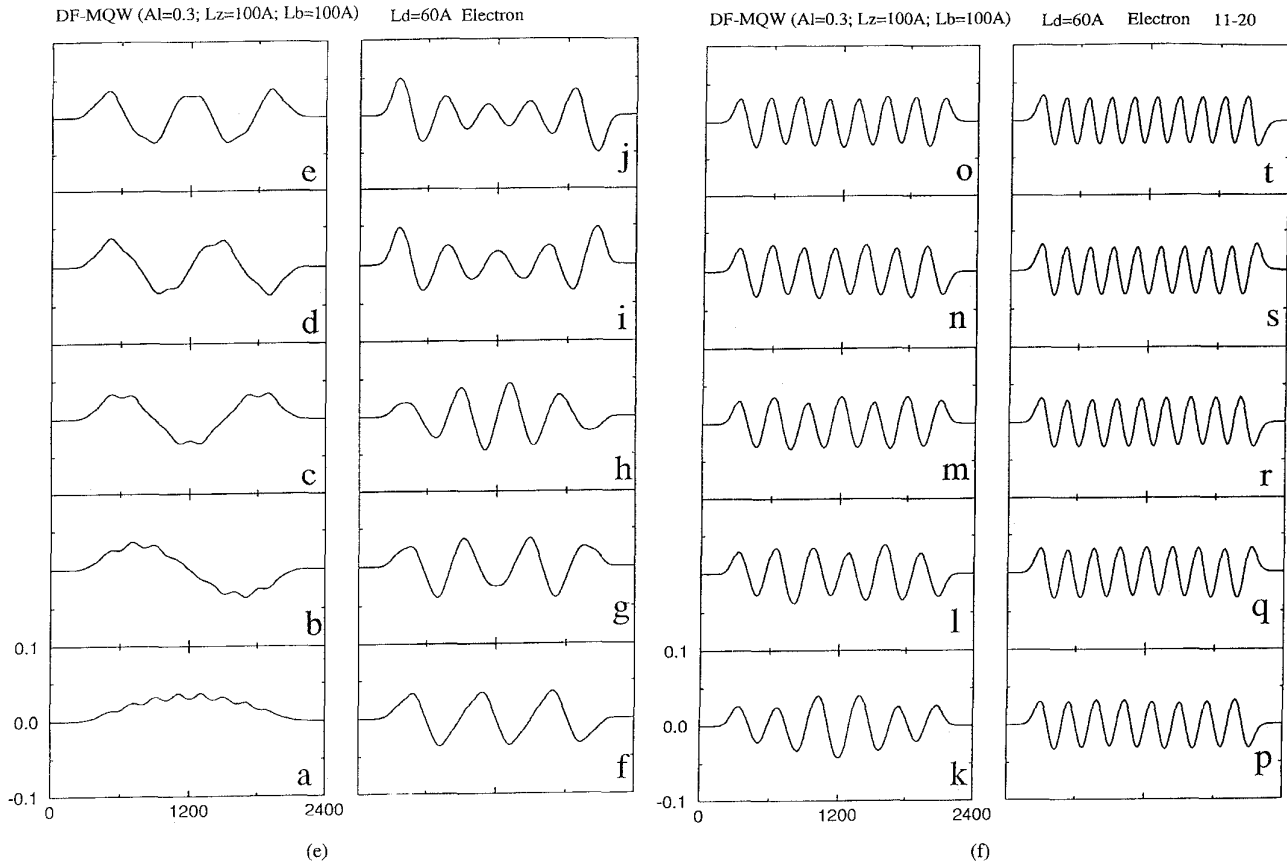


Fig. 6. (Continued.) The first (lowest energy) 20 eigenstates of electron for three cases where a–j denote the first 10 and k–t denote the next 10. Al = 0.3, $L_z = 100 \text{ \AA}$, and $L_b = 100 \text{ \AA}$ for (e)–(f) $L_d = 60 \text{ \AA}$.

cases. For a particular subband, there are a total of $N_w (=10)$ modes coupled, which are degenerate. It can be seen that these wavefunctions are either symmetric ($\xi = 1, 3, 5, 7, 9$) or antisymmetric ($\xi = 2, 4, 6, 8, 10$) for all L_d values and both minisubbands. Also, the overall wavefunction is enveloped by either an odd or an even function due to the cladding-layer confinement of the entire MQW core, as the wavefunctions are not evenly distributed over each well. Exceptions could be found in the upper states at large interdiffusion extent, such as ($\ell = 2; \xi = 5$) and $L_d = 60 \text{ \AA}$, where the MQW core is almost a uniform material (see Fig. 2), and it behaves like a thick single-QW layer, hence uniformity is restored. However, a peculiar feature of the wavefunctions $\psi_{C1,9}$ and $\psi_{C1,10}$, which can be observed in the case of $L_d = 40 \text{ \AA}$, is that they are localized to the extremes of the MQW core layers. This confirms the delocalization effect due to nonuniformity of the MQW's after interdiffusion. The nonuniformity of the wavefunctions can also be observed for the cases of $HH(L_d = 40 \text{ \AA}; \ell = 1, 2)$ and $HH(L_d = 20 \text{ \AA}; \ell = 1)$ but not in any of the LH cases considered here. This demonstrates the sensitivity of the energy level to the confinement shape of the well.

C. Optical Transitions

The lowest interband transition energy, i.e., bandgap, of the DF-MQW is shown in Fig. 7 as a function of L_d , and the exact values are given in Table IV for reference. It can be

TABLE IV
DF-MQW BANDGAP ENERGY, $E_{11} = E_g(L_d) + E_{C1,1} + E_{HH1,1}$

$L_d (\text{\AA})$	$E_{11} (\text{eV})$
GaAs	1.42400
0	1.46340
5	1.46866
10	1.48191
20	1.53381
30	1.59335
40	1.63288
50	1.64974
60	1.65383
70	1.65438
80	1.65444
90	1.65446
100	1.65448
500	1.68822
$\text{Al}_{0.3}\text{Ga}_{0.7}\text{As}$	1.84634

seen that during the initial interdiffusion stage the bandgap rises rapidly up to $L_d = 50 \text{ \AA}$, which produces a blue shift of

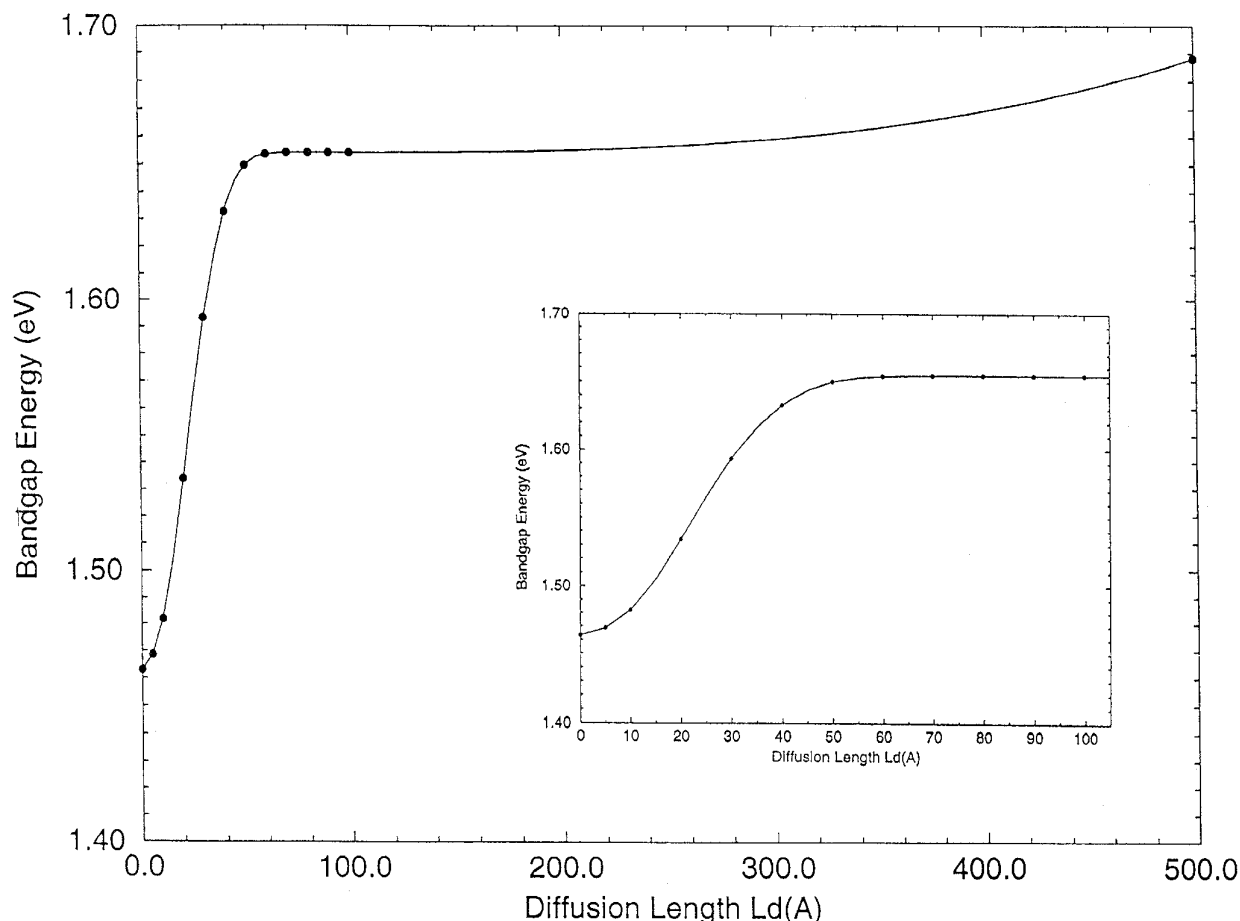


Fig. 7. The DF-MQW band-gap energy as a function of L_d . Inset shows details of the initial interdiffusion for $L_d \leq 100$ Å.

TABLE V
CONTRAST RATIO (CR) OF A WAVEGUIDE-TYPE
LONGITUDINAL DF-MQW MODULATOR. THE LENGTH OF THE
MODULATOR IS 100 μm AND TE POLARIZATION IS ASSUMED

L_d (Å)	Field (OFF)	Field (ON)	λ (μm)	CR (dB)
0	100 kV/cm	0	1.4375	90.00
10	100 kV/cm	0	1.4676	176.23
20	100 kV/cm	0	1.5369	164.97

≈ 186 meV, after which it then leveled off with only a very gradual increase. This rapid increase is a consequence of the QW effect, and the slow increase is due to a bulk-like material interdiffusion between the cladding layer and the uniform core. The interdiffusion-induced blue shift of the bandgap, ≈ 70 meV, at $L_d = 20$ Å compares well with experimental measurement [19] of 61.3 meV for a similar structure at $L_d \approx 17$ Å.⁴ The TE and TM polarized absorption coefficients are shown in Fig. 8(a) and (b), respectively, for several cases of L_d . The typical signature of the two-dimensional density of states (stepped staircase) can be observed for L_d up to 60 Å. The magnitude of the first step rises to an absorption of \approx

⁴Note that in the experimental data in [21, Fig. 1], a 80-Å-wide well and barrier MQW structure is considered, and the parameters used in the determination of the interdiffusion coefficient are not the same as have been used in the present model. Their 950° 15 s RTA corresponds to $L_d = 17$ Å.

5000 cm^{-1} , which is in good agreement with experimental data [33] for the $L_d = 0$ case. The blue shift of the absorption edge due to interdiffusion is more enhanced in the region of $10 \text{ Å} \leq L_d \leq 30 \text{ Å}$; this corresponds to a band-width of ≈ 0.1 eV (55 nm) which is half of the ≈ 0.2 -eV (102 nm) width over the range of $0 \text{ Å} \leq L_d \leq 100 \text{ Å}$; which is because of the sharp increase in the MQW core bandgap (the first subband $\ell = 1$) for this interdiffusion. For small $L_d (\leq 10 \text{ Å})$ and $L_d (\geq 30 \text{ Å})$, the bandgap energies remain approximately constant, as seen in Fig. 3. These effects are due to the nature of the interdiffusion for small L_d , where only the well shape has been changed while the depth of the well remains unchanged. However, during the intermediate stages (medium size L_d) not only is the well shape changed but also the depth of the well is reduced, which implies a much more enhanced interband transition energy which gives rise to a much larger blue shift of the bandgap. As the interdiffusion proceeds further, i.e., the latter stages of interdiffusion (large L_d), the well-confinement profile turns into that of a uniform material so that for the interdiffusion process to modify such a thick (2000-Å) well layer is considerably slower than for the thin (100-Å) well layers. It is still a single-well structure, but since the well is so thick, the quantum-confinement effects are very small (if they are present at all), and therefore its optical

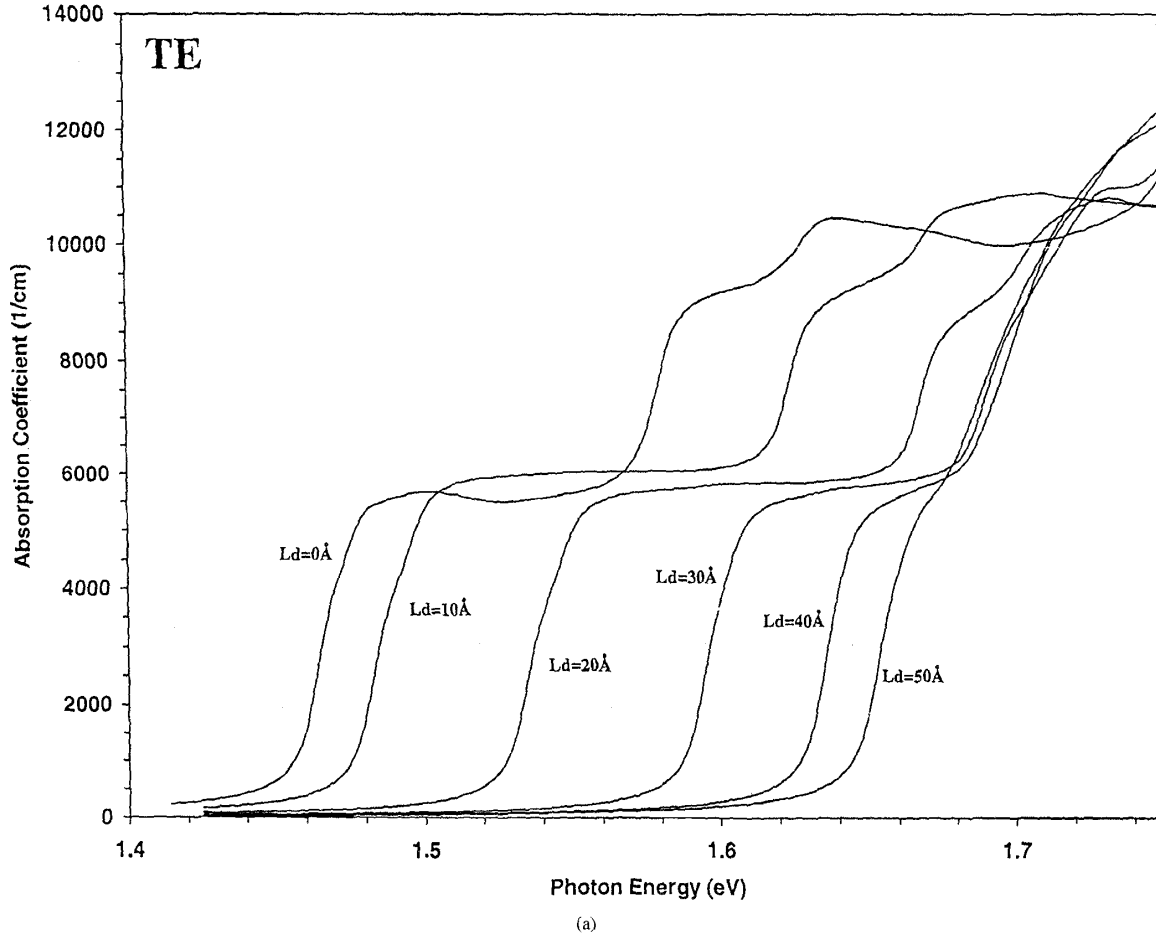


Fig. 8. (a) TE polarized absorption coefficients spectra for $0 \text{ \AA} \leq L_d \leq 80 \text{ \AA}$.

properties are very insensitive to the well-shape change. These are demonstrated in Fig. 8, where rich features can be observed in the absorption spectrum due to band-mixing, for ($L_d \leq 60 \text{ \AA}$), as the interdiffusion proceeds further ($L_d \geq 60 \text{ \AA}$), a bulk-like smooth absorption spectrum is produced which is consistent with the theory [10].

D. Device Implication

The effect of interdiffusion on the performance of a typical waveguide-type modulator is present here by a quantitative estimate of the conventional contrast ratio (power ON/OFF). For the as-grown MQW ($L_d = 10$), the CR is 90 dB at $\lambda = 1.438 \text{ eV}$, based on the calculation for a modulator with a longitudinal length of $100 \text{ }\mu\text{m}$. When L_d increases to 10 and 20 \AA , the CR increase to 176 dB ($\lambda = 1.48 \text{ eV}$) and 164 dB ($\lambda = 1.54 \text{ eV}$), respectively. This implies the electro-absorptive modulation performance improves with interdiffusion. Moreover, the operation wavelength can be varied from 1.438 eV ($L_d = 0$) to 1.54 eV ($L_d = 20 \text{ \AA}$) which provides a tuning range of almost 60 nm. The only drawback is the increase of propagation loss when L_d increased to 10

and 20 \AA . This loss can be reduced if a larger field is applied where the operation wavelength is shifted further away from the exciton edge and the tuning range can be enlarged if diffusion length is increased. However, if L_d is extended to beyond 30 \AA , the quantum confinement will be diminished as can be seen in Fig. 8(a) and (b) where the two-dimensional nature of the staircase phenomenon is gone at $L_d = 40 \text{ \AA}$. Also for electro-absorption, because of losing the two-dimensional absorption, the field strength is restricted to within a small value ($F \leq 70 \text{ kV/cm}$) for cases of large interdiffusion extents ($L_d \geq 30 \text{ \AA}$). Thus, in terms of design versatility, this may limit the realization of a wide-bandwidth low-loss modulator. Therefore, optimization of the DFQW structures, including the choice of III-V materials, should be considered, which forms the future work.

IV. CONCLUSION

A comprehensive analysis of the interwell coupled eigenstates and their interband transitions in the interdiffusion modified $\text{Al}_{0.3}\text{Ga}_{0.7}\text{As-GaAs}$ MQW structures has been presented. A full numerical calculation is considered without any

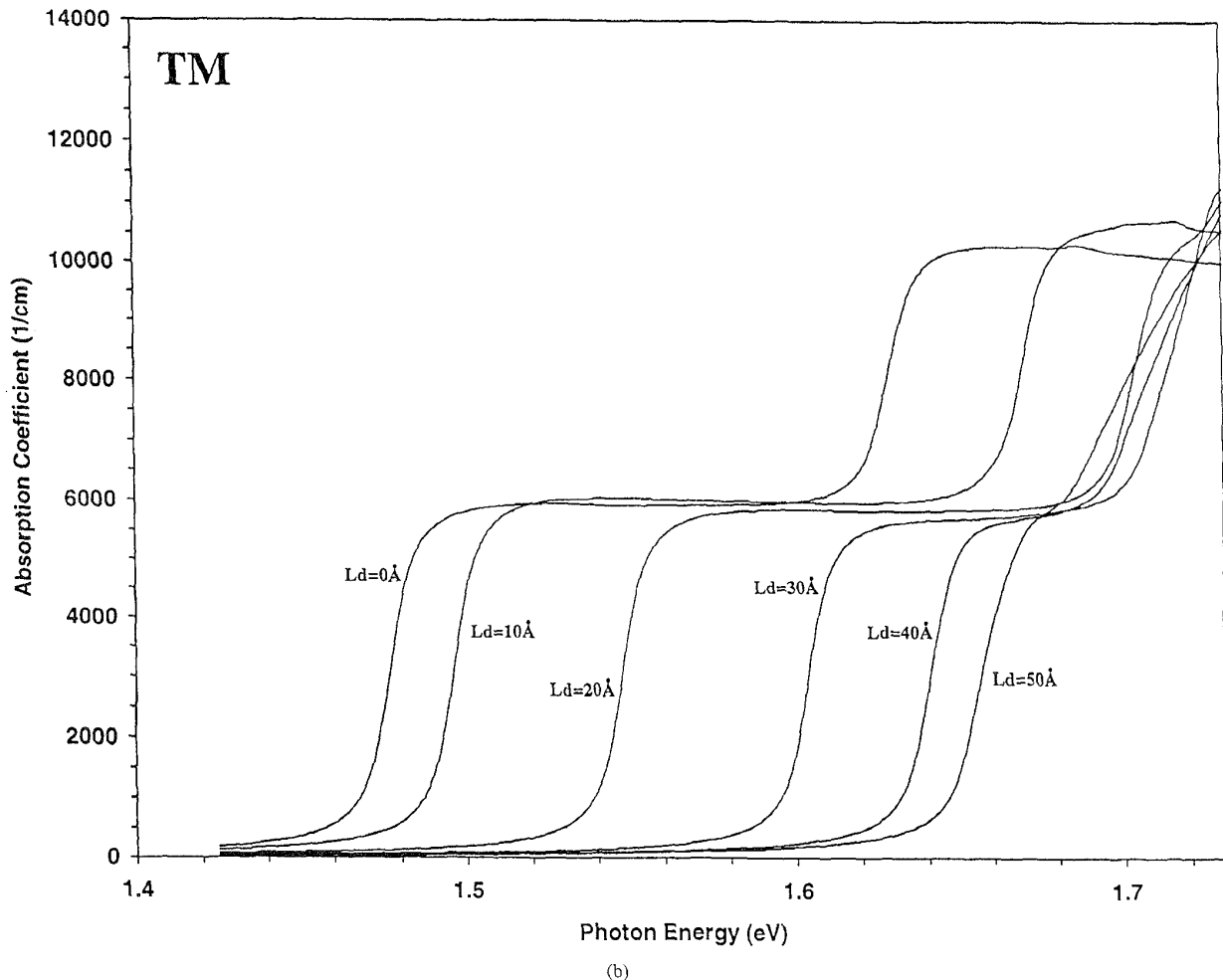


Fig. 8. (Continued.) (b) TM polarized absorption coefficients spectra for $0 \text{ \AA} \leq L_d \leq 80 \text{ \AA}$.

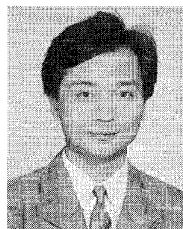
approximation or presumption of the eigenstates. The results show that in the initial interdiffusion ($L_d \leq 10 \text{ \AA}$) of the quantum-well structure with equal well and barrier thickness of 100 \AA , the wavefunctions behave as in the case of a single quantum well with almost no well-to-well coupling of the states. However, as interdiffusion proceeds further, the eigenstates in each subband form mini-bands, as is the case of a superlattice, and eventually become a bulk-like material for ($L_d \geq 100 \text{ \AA}$). Distortion of the coupled wavefunction can also be observed as a consequence of the nonuniformity of the confined wells at the extremes of the MQW core due to interdiffusion from the thick cladding layers. A rapid increase of the bandgap due to interdiffusion is observed in the initial stage of interdiffusion, which corresponds to an energy blue shift of $\approx 186 \text{ meV}$, while the overall shift up to $L_d = 500 \text{ \AA}$ is 225 meV . The TE and TM polarized absorption coefficients are calculated, including the effect of valence band-mixing. Results show that the blue shifting ($\approx 100 \text{ meV}$) of the absorption edge is more enhanced in the range of $10 \text{ \AA} \leq L_d \leq 30 \text{ \AA}$, while the absorption strength remains the same. The absorption at C1-HH1 transition for the square quantum-well case is in good agreement with existing experimental

data. The interband transition energies and optical properties of interdiffused MQW's have important implications in the design of optoelectronic devices, such as waveguides and modulators. The present results suggest that a large energy shift and, hence, the large refractive-index difference, can be achieved using the as-grown material and that the earlier stage of interdiffusion should produce large refractive-index changes which are suitable for the realization of laterally confined stripe optical waveguides. The spectral-absorption curves also reflect strong two-dimensional quantum-well properties in the beginning of interdiffusion. As a consequence, quantitative estimates for the waveguide-type of modulator suggest a high-absorption loss and low-contrast ratio when interdiffusion is gone too far. Further work is under way in the modeling and analysis of electrooptic effect in these interdiffused MQW structures, together with extensive experiments to support the theoretical analysis.

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